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A Compact Mach-Zehnder Interferometer using Composite Plasmonic Waveguide for Ethanol Vapor Sensing

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Abstract— The Finite Element Method (FEM) has attracted a considerable interest in the past few decades for the analysis of a wide range of dielectric waveguides. This method can handle isotropic and anisotropic material properties and arbitrary shaped complex dielectric discontinuities more efficiently and accurately than any other methods. A modified H-field based full-vectorial finite element method is used for a rigorous analysis of a composite plasmonic waveguide (CPWG) as an efficient ethanol vapor sensor where a porous ZnO (P-ZnO) layer is used as low index material in between high index silicon and silver metal layer. Enhanced field confined into low index slot is utilized for ethanol vapor sensing which has many potential applications in food industries. It is reported here that, a high waveguide sensitivity over 0.7 per RIU could be realized with our proposed design depending on the porosity of the ZnO layer. For accurate detection of refractometric changes a compact Mach-Zehnder interferometer is designed where a maximum phase sensitivity of 0.30, 0.34, 0.38 and 0.40 is shown to be achieved for ~50% volume fraction of ethanol into porous ZnO layer with porosity, \( P = 30\% \), \( 40\% \), \( 50\% \) and \( 60\% \), respectively. The complete investigation has been carried out at the well-known telecommunication wavelength 1550 nm and with our in-house, accurate full-vectorial FEM code.

Index Terms— Finite element method (FEM), surface plasmon polariton (SPP), composite plasmonic waveguide, Mach-Zehnder Interferometer (MZI), Sensor.

I. INTRODUCTION

MODERN industries use ethanol (\( \text{CH}_3\text{CH}_2\text{OH} \)) as one of the most important constituent. This highly flammable substance has a high impact on daily life, from chemical and pharmaceutical products to heavy automobile and fuel engineering. When ethanol vapor mixes with air, explosive fire can result if accidentally ignited. Only 3.5% ethanol vapor in air can cause explosion, this often termed as lower explosion limit. Besides, the upper explosion limit is 19% by volume of air [1]. Mishandling, leaking, spilling contamination failures can release the liquid ethanol which causes flammable vapor. This results environmental pollution and also severe health risks. Human body initially breaks ethanol into acetaldehyde which increases the risk factor of liver cirrhosis and cancer. Therefore, accurate and high sensitive sensing of ethanol vapor in industrial environment is crucial. Several gas sensing mechanisms, such as spectrometric sensing [2], electrochemical [3], [4], solid state semiconductor [5] and microcontroller based devices [6], have been reported and demonstrated in recent years. Besides, dielectric waveguide based interferometric and resonating structure, for breathing [7], \( \text{H}_2 \) [8] and \( \text{CH}_3\text{CH}_2\text{OH} \) [9] sensing is more convenient for its high sensitivity and compact lab-on-a-chip design. In this paper, we proposed a novel, compact ethanol vapor sensor based on hybrid plasmonic based horizontal slotted [10] waveguide which offers a high sensitivity along with nanometer scale footprint.

Integration of photonic devices and nano-electronics now became a challenge due to ingrained diffraction limit of electromagnetic energy supported by dielectric media. The surface plasmon polaritons (SPPs) can be one of the solutions to overcome this difficulty. Comparing other nano-scale waveguides, such as, high-index contrast silicon-on-insulator (SOI) nano-wires and photonic crystals (PCs), surface plasmon (SP) shows a true nano-scale light guiding [11], [12]. The light guiding characteristics of conventional dielectric waveguides and pure plasmonic waveguides are opposite in nature. A high-index contrast SOI nano-wire confines light in the high index region. A very low propagation loss and hundred nanometer scaled mode area are also key properties of these structures [13]. However, a pure metal plasmonic waveguide provides a sub-wavelength scale light guiding but with very high propagation loss [14] - [17]. This in turn demands an accurate engineering to design the plasmonic based waveguides to channelize the unique features of SPPs in the field of linear, non-linear photonic devices [18], [19] and sensing applications [20] - [21].

Surface Plason Polaritons (SPPs) are surface waves tightly confined at the interface between metal and dielectric media. At optical and near infra-red (IR) region, metal has negative dielectric constant whereas dielectrics show a positive value. This complimentary nature at the interface
excites electromagnetic surface wave that propagates until the field dies by material absorptions and scattering into surrounding media. The electromagnetic surface wave is a unique light-matter interaction that contains a coupled state of the electromagnetic wave to conductor's free electrons plasma oscillations. The SPPs are transverse magnetic (TM)-polarized in nature and evanescently confined in the direction of propagation. The SPPs can be excited either by electrons or photons with same frequency and momentum. In this piece of work the photons having telecommunication wavelength $\lambda = 1550 \text{ nm}$ is used for SPPs excitation. Analytical solution to characterize the modal properties of electromagnetic field generated on both side of the metal and its integration with dielectric waveguide mode for a complex structure is not easy. Numerical modelling of complex plasmonic structure offers possible solution for sub-wavelength plasmonic device design and its performance analysis. A full-vectorial $\mathbf{H}$-field based FEM is used as a simulation tool for the device designs.

This report is organized as follows. In the 2$^{nd}$ section we summarize the modified mathematical steps of FV-FEM as well as the Lorentz-Lorenz formula to calculate equivalent refractive index of P-ZnO with ethanol vapor. The 3$^{rd}$ section describes the design of our proposed horizontal slotted composite plasmonic waveguide (CPWG). In the 4$^{th}$ section, the waveguide design parameters are optimized and evaluate its performance as an ethanol vapor sensor. The 5$^{th}$ section demonstrates the design and performance investigations of Mach-Zehnder interferometer using the P-ZnO based horizontal slotted CPWG. In section 6, the fabrication challenges are mentioned and finally, all findings are summarized in the conclusive part.

II. THEORY

While designing of a pure [16], [17] and composite plasmonic waveguide (CPWG) [15], [18], [20], [22] an exact calculation of real and complex modal effective indices, dominating and non-dominating field components and hybridness of quasi-TM and quasi-TE modes are very important. Besides, in case of a sensor design, a rigorous analysis is also needed to calculate the confinement factors ($\Gamma$) of selective regions along with the modal effective index change due presence of a sensing medium. All aforementioned parameters could be found by solving the Maxwell's equations for the waveguide. In most cases the partial differential equations (PDEs) becomes complex, which are inadequate to solve by analytical or semi-analytical approach. Thus, a full vectorial numerically efficient finite element method (FV-FEM) could be used to determine the accurate modes of these waveguides. 2D FV-FEM uses for modal solution of the waveguide problem [23], [24] and 3D FV-FEM uses to determine the resonating nature of a structure [24], [25].

A. Full Vectorial Finite Element Method (FV-FEM)

In this report, we have used the $\mathbf{H}$ field based variational formulation. This method has a considerable advantage over other formulations, such as, $\mathbf{E}$ and mixed $\mathbf{E+H}$ field formulations, proposed in [26]. Here the $\mathbf{H}$ field components are continuous at the dielectric interfaces and this is true even when index contrast is high, such as metal-dielectric interface. Besides, the natural boundary condition associated with this formulation is a perfect electric wall (PEW). Thus, only necessary boundary condition (PEW and/or perfect magnetic wall (PMW)) needs to be imposed depending on the desired modes of the waveguides. One-fold and two-fold symmetrical advantage of the structure can be considered by proper application of PEW and PMW boundary conditions. Degeneration of different polarized modes can also be reduced with this mathematical trick. As a result, a better accuracy could be achieved with a much lower computational resource.

The variational formulation is based on Maxwell's two curl equations, so that, their Euler equations follow the Helmholtz's equation but do not necessarily satisfy the Maxwell's two divergence equations. This causes the presence of spurious modes all over the eigenvalue matrix along with the real modes. This formulation deficiency could be nullified by introducing a second part, so that the Euler equation of the modified functional $J_e$ satisfy all four Maxwell's equations.

$$J_e = \left[ \iint (\nabla \times \mathbf{H})^* \cdot \mathbf{\varepsilon}_r^{-1} (\nabla \times \mathbf{H}) \, dxdy \right]$$
$$+ \, p \, \left[ \iint (\mathbf{\nabla} \cdot \mathbf{H})^* (\mathbf{\nabla} \cdot \mathbf{H}) \, dxdy \right]$$
$$- \, k^2 \left[ \iint \mathbf{H}^* \cdot \mathbf{\mu}_r \mathbf{H} \, dxdy \right]$$

(1)

Here the functional $J_e$ represents the numerical errors due to domain discretization.
Rahman and Davies previously proposed the penalty function method [27] where a weighting factor $p$, shown in equation (1), was incorporated to externally balance the curl and divergence parts. As this penalty term is expected to almost equal to $1/n_{eff}^2$ of the waveguide, this has been very useful to give accurate modal solutions for waveguides with only positive dielectric constants. Instead of the penalty method reported earlier, we proposed here a more direct approach. This seems to be more effective for pure and composite plasmonic waveguide problems where the local material permittivity may have both positive and negative values. The plasmonic field variations occurs in small dimensions. To incorporate that the additional divergence integral is modified by considering the local permittivity rather than the global penalty parameter ($p$) used earlier. Here, during formation of global eigenvalue equation each discretized element’s individual dielectric constant is considered inside the divergence part. The modified form of H-field based variational formulation can be written in the form

$$k_0^2 = \left(\frac{\omega}{c}\right)^2$$

$$= \left[\int (\nabla \times \mathbf{H})^* \varepsilon_r^{-1} (\nabla \times \mathbf{H}) \, dx \, dy + \int (\nabla \cdot \mathbf{H})^* \varepsilon_r^{-1} (\nabla \cdot \mathbf{H}) \, dx \, dy\right]$$

$$\left/ \int \mathbf{H}^* \cdot \mu_r \cdot \mathbf{H} \, dx \, dy \right.$$

Here $k_0$, $\omega$, $\varepsilon$ and $\mu$ are the wavenumber ($k_0^2$ represents the eigenvalue), angular frequency, relative permittivity and permeability tensor, respectively. The quasi-TE and TM modes can be obtained by post-processing the eigenvectors of specific eigenvalues.

Design and optimization of the vapor sensor needs a rigorous analysis of power confinement into selected slot region of the CPWG. The confinement factor of the horizontal slot can be defined by using the eigenvectors obtained from equation (2).

$$\Gamma_{slot} = \frac{\int_{slot} Re(E \times H^*), \hat{z} \, dx \, dy}{\int_{\infty} Re(E \times H^*), \hat{z} \, dx \, dy}$$

Where $Re$ denotes the real part of complex electric ($E$) and magnetic ($H$) fields, respectively and * denotes the complex conjugate and integrations are carried out over the whole computation domain for denominator and only in the slot region for numerator.

B. Equivalent index of P-ZnO due to capillary condensation

Our proposed ethanol vapor sensor contains a horizontal layer of porous ZnO (P-ZnO) as a low index medium. P-ZnO has lower refractive index than a bulk ZnO, as the material pores are filled with air ($n = 1$). The equivalent refractive index has an inverse relation with the number of pores in unit volume, called porosity ($P$). Increased curved empty area due to porosity results the absorption and condensation of vapor or gas substances. Pore sizes ranging from 2 to 50 nm (mesoporous) of a P-ZnO layer possess the surface area around 1000 $m^2/g$ [9]. When the porous layer is kept in contact with the measuring analyte the air ($n = 1$) filled voids are replaced by condensed analyte ($n > 1$). Depending on the different volume fraction of absorbed and condensed analyte,
the effective refractive index as well as dielectric constant of P-ZnO changes.

To make our device efficient, different types of P-ZnO layer templates could be used, such as, porous flakes composed ZnO spheres [28], P-ZnO nanosheets [29] and nanoplates [30]. All these types of P-ZnO layers composites of nanometer scaled pores exploit ultrahigh pore density with great enhancement of surface-to-volume ratio. P-ZnO spheres, nanosheets and nanoplates are mesoporous with pore diameters ranging from 2 to 50 nm. The nanosheet contains average pore size of 39 nm [29]. Operating temperature is an important parameter for metal-oxide semiconductor based sensors. The P-ZnO sphere layer shows an enhanced selective response to 100 ppm ethanol at 280°C. Similarly, a strong response in ethanol sensing can be observed around 400°C to 450°C for nanosheets and nanoplates [29], 30. In terms of selectivity and response-recovery time, all three P-ZnO configurations show excellent selectivity and much lower response and recovery time (10 and 15 s, 7 and 19 s, 32 and 17 s) to ethanol vapor compared to methanol, acetone, chlorobenzene, methane at 280°C [28], 400°C [29] and ~450°C [30] for 2, 200 and 100 ppm of ethanol, respectively. Use of these P-ZnO templates make the CPWG more stable and efficient for ethanol vapor sensing.

Various effective quantitative models, such as, Maxwell-Garnet theory, Bruggeman model and Lorentz-Lorenz model have been proposed to determine the equivalent permittivity of heterogeneous media [31]. In our work, we used the Lorentz-Lorenz model to determine the effective refractive index of P-ZnO and the equivalent refractive index (n<sub>eff</sub>) as

\[
\frac{n^2 - 1}{n^2 + 2} = (1 - p) \left( \frac{n_e^2 - 1}{n_e^2 + 2} \right) + (p - V) \left( \frac{n_d^2 - 1}{n_d^2 + 2} \right) + V \left( \frac{n_a^2 - 1}{n_a^2 + 2} \right)
\]

Here P is the ZnO layer porosity, V is the volume fraction of liquid after capillary condensation. n<sub>e</sub>, n<sub>c</sub> and n<sub>d</sub> are the index of refraction of air (n<sub>a</sub> = 1), homogenous (bulk ZnO) and dispersed medium (condensed vapour), respectively. We have considered the P-ZnO layer of porosity P = 30%, 40%, 50% and 60%. Corresponding refractive index (n<sub>P-ZnO</sub>) variations and equivalent refractive index of P-ZnO due to different volume fraction of ethanol are presented in Fig. 1. As expected, with increased of porosity, n<sub>P-ZnO</sub> decreases as shown by a solid black line. On the other hand, while the air pores are replaced by condensed ethanol the equivalent index of refraction increases. At room temperature (20°C), the bulk ZnO refractive index is taken as 1.9267, derived from the
dispersion formula in [32] and the condensed ethanol refractive index is derived by using the Sellmeier equation given in [33].

\[ n^2(\lambda) - 1 = \frac{A_1 \lambda^2}{\lambda^2 - B_1} + \frac{A_2 \lambda^2}{\lambda^2 - B_2} \]  

(5)

Here \( A_{1,2} \) and \( B_{1,2} \) denotes the material property parameters and absorption wavelengths. The constant values used for mathematical analysis are, \( A_1 = 0.83189 \), \( A_2 = -0.15582 \), \( B_1 = 0.00930 \) \( \mu m^{-2} \) and \( B_2 = -49.45200 \) \( \mu m^{-2} \).

III. HORIZONTAL SLOTTED COMPOSITE PLASMONIC WAVEGUIDE

Plasmonic waveguides are very useful for nanodimensioned photonic sensing devices. In pure plasmonic and CPWG, enhanced sub-diffraction limited light confinement on the metal-dielectric interface make this structure very attractive for local surface and bulk bio-chemical and gas sensing. The presence of lossy metal the bounded SPP modes can only be guided over a small distance. To utilize the advantages of localized plasmonic fields along with short mode propagation length \( (L_p) \) the metal layer is integrated with other dielectric materials. The propagation length \( (L_p) \) is defined by \( L_p = 1/2\alpha = \lambda/4\pi \text{Im}(n_{\text{eff}}) \), where \( \alpha \) denotes the attenuation constant and \( \text{Im}(n_{\text{eff}}) \) denotes the imaginary part of effective index. Metal dielectric composite structure helps the plasmonic modes to propagate over a comparative longer distance. Thus, with proper engineering a composite plasmonic waveguide (CPWG) can be designed, which can be useful for local bio-chemical and gas sensing.

The schematic diagram of our proposed horizontal slotted CPWG is shown in Fig. 2(a). The waveguide consists of composite materials, such as lossy metal (Ag), porous ZnO (P-ZnO), silicon (Si) and silica (SiO2). A horizontal slot waveguide can be formed by depositing a nano-scaled thick \((t_{Ag})\) silver layer on top of a P-ZnO, which is used as a low index slot region in between the metal and high index Si. The refractive indices considered for simulations are, \( n_{Ag} = 0.13880 + j/11.310 \) [34], \( n_{Si} = 3.4757 \) [35], \( n_{SiO2} = 1.4440 \). The necessary boundary condition of electromagnetic field demands a continuity of normal component of electric flux density \((D)\) at the interface boundaries that results a high \( E_y\) field discontinuity at those interfaces. These field characteristics make this waveguide very attractive for integrated sensing device due to strong light matter interaction in the slot region. Here ethanol vapor is used as a sensing medium. Due to capillary condensation ethanol vapor molecules are absorbed by the ZnO pores and condensed as liquid ethanol. Thus, depending on percentage of absorbed ethanol vapor the refractive index of P-ZnO layer changes. The relation between equivalent refractive index of P-ZnO and volume fraction of ethanol already has been discussed in Section 2.3. These refractometric change can easily be detectable by an accurate measurement of waveguide’s real part of effective index change, \( \Delta \text{Re}(n_{\text{eff}}) \) of the quasi-TE and TM modes.

An efficient H-field based FEM code is used to simulate the CPWG. In Fig. 2(a), only the right hand side section bordered by black line have been considered for simulation as we have exploited the available symmetry of the structure. To obtain an accurate solution and field continuity of CPWG, the boundary conditions are applied along the symmetry line. In this structure, a perfect magnetic wall (PMW), \( \hat{n} \times \hat{H} = 0 \) is applied along the symmetry line (along y-axis) as the \( H_x \) and \( E_y \) fields of fundamental mode have even symmetry along the y-axis. Figures 2(b) and (c) depict the \( E_y \) and \( H_x \) field contours of fundamental \( H_x^1 \) mode. The 1D-line plot of \( E_y \) and \( H_x \) fields of fundamental \( H_x^1 \) mode is shown in Fig. 3. The \( E_y \) field by the red solid line indicates a sharp field enhancement into low index horizontal slot region. The \( H_x \) field is denoted by blue...
dashed-dotted line which shows light guidance by the high index Si core. To obtain an explicit sensor design a rigorous investigation is needed to estimate the optimized waveguide parameters, dominant, non-dominant field distributions and power confinement into different waveguide regions due to refractometric changes into slot area. For simplicity, we fixed the Si nano-wire and Ag metal thickness as 220 nm and 100 nm, respectively. The rest of device geometries, such as, waveguide core width ($W_{\text{core}}$) and slot thickness ($t_{\text{slot}}$) are optimized for best performance. Throughout the simulation process, only half of the waveguide is discretized with 1,280,000 triangular mesh elements. Mesh distribution is also an important part for plasmonic waveguides. As the metal surface possess a sub-wavelength field confinement into nano-scaled region, a sufficient dense mesh distribution is required in the thin metal area for accurate solutions. The maximum element size used around the metallic area is better than 0.2 nm.

IV. DESIGN PARAMETERS OPTIMIZATION AND PERFORMANCE EVALUATION

Figures 4 and 5 show variation of the real part of the effective index, $Re(n_{\text{eff}})$ and modal propagation length $L_p$ against the horizontal slot thickness $t_{\text{slot}}$, respectively. To benchmark our in-house code over 30 years, we have also simulated a SOI based horizontal slotted hybrid-plasmonic waveguide proposed by Alam et al. [18]. We have considered the same waveguide dimensions ($W_{\text{core}} = 350$ nm, $t_{\text{Ag}} = 200$ nm, $t_{\text{Si}} = 200$ nm and $t_{\text{substrate}} = 2.0$ μm) and same material refractive indices for our simulations. Our simulated $Re(n_{\text{eff}})$ and $L_p$ data are shown by the orange dotted lines in Figs. 4 and 5. Our results matches excellently with the published results (purple triangles) reported in [18] where they have used a commercial software for simulations.

In this study, we have taken three different widths 350 nm, 450 nm and 550 nm shown by green, red and blue lines, respectively. Corresponding $Re(n_{\text{eff}})$ and $L_p$ variations of fundamental quasi-TE and TM mode are shown by the dashed-dotted and solid lines, respectively. As $t_{\text{slot}}$ increases the $Re(n_{\text{eff}})$ decreases gradually for fundamental quasi-TE mode but increases for fundamental quasi-TE mode, respectively. It can be observed that for $W_{\text{core}} = 350$ nm and 450 nm modal degeneracy occurs at $t_{\text{slot}} = 108$ nm and 48 nm, respectively when effective indices of the quasi-TE and quasi-TM modes became equal. Modal degeneracy points are encircled by black line and corresponding $Re(n_{\text{eff}})$ values are also given in Fig. 4. Here for CPWG, the effective dominant mode for sensing is the quasi-TM supermode where a surface plasmonic mode is coupled with dielectric mode into low index slot region. It can also be noted from Fig. 4 that for a fixed $t_{\text{slot}}$ the $Re(n_{\text{eff}})$ also decreases with $W_{\text{core}}$. The $L_p$ variations with $t_{\text{slot}}$ in Fig. 5 show a rapid increment for quasi-TE as here the field is mostly confined and also guided by the low-loss dielectric regions but the quasi-TM mode shows a comparative slow increment with thickness of P-ZnO dielectric material into slot as here the field profile is dominated by the SPPs generated by the lossy metal-dielectric interface.

Figures 6 and 7 show the quasi-TE and TM confinements with $t_{\text{slot}}$ and $W_{\text{core}}$, respectively. The TE and TM slot confinements ($\Gamma_{\text{TM slot}}$ and $\Gamma_{\text{TE slot}}$) with $t_{\text{slot}}$ show an interesting feature. For three fixed $W_{\text{core}}$, the $\Gamma_{\text{TM slot}}$ increases with $t_{\text{slot}}$, reaches maximum 41.79% at $t_{\text{slot}} = 70$ nm and then decreases gradually with further increment. It can also be noticed that the CPWG with $W_{\text{core}} = 450$ nm, shown by the red solid line, confines higher electromagnetic energy than other two core widths (550 and 350 nm), shown by blue and green solid lines, respectively. The $\Gamma_{\text{TE slot}}$ for all three $W_{\text{core}}$ increase with increase of slot thickness shown by the dashed-
dotted lines. But these values are considerably lower than the TM mode confinement. These curves intersect each other at \( t_{\text{slot}} = 68 \, \text{nm} \) and exhibits only around 3.56\% power confinement. As we are designing a plasmonic sensor, the slot confinement due to SPP and dielectric supermode is our most concern. As a result, we focused only on \( \Gamma_{\text{TM slot}} \) variation and the maximum confinement is obtained for optimized slot thickness, \( t_{\text{slot}} = 70 \, \text{nm} \). Further optimization of \( W_{\text{core}} \) for 70 nm and 100 nm slot height has been carried out and the result is presented in Fig. 7. Here, the red and green solid lines represent the \( \Gamma_{\text{TM slot}} \) variations with \( W_{\text{core}} \) for two fixed \( t_{\text{slot}} = 70 \, \text{nm} \) and 100 nm, respectively. As \( W_{\text{core}} \) increases the \( \Gamma_{\text{TM slot}} \) grows and confines maximum 41.80\% and 41.09\% TM field into 70 and 100 nm slot, respectively at \( W_{\text{core}} = 450 \, \text{nm} \). Thus, the optimized CPWG core width can be taken as 450 nm. From the plots in Figs. 6 and 7 it can be seen that a 100 nm slot confines 41.09\% TM field. As there was not much difference in \( \Gamma_{\text{TM slot}} \) for \( t_{\text{slot}} = 70 \, \text{nm} \) and 100 nm and a few nm extra thickness may be convenient to accommodate more number of pores in mesoporous ZnO layer, we have finally considered slot thickness as 100 nm. Throughout the optimization process, the Si nano-wire and Ag thickness are kept fixed at \( t_{\text{Si}} = 220 \, \text{nm} \) and \( t_{\text{Ag}} = 100 \, \text{nm} \), respectively but if desired these can also be optimized. Hence all the optimized CPWG parameters can be listed as, \( W_{\text{core}} = 450 \, \text{nm} \), \( t_{\text{slot}} = 100 \, \text{nm} \), \( t_{\text{Si}} = 220 \, \text{nm} \) and \( t_{\text{Ag}} = 100 \, \text{nm} \) for 40\% ZnO porosity.

Next, we analyzed the CPWG performance with the presence of ethanol vapor. Absorption of different percent ethanol vapor changes the equivalent refractive index of P-ZnO with the help of capillary condensation. The equivalent refractive index depending on the volume fraction of ethanol was calculated by using Lorentz-Lorenz formulation, given in equation (3) and also shown in Fig. 1. The quasi-TM and TE real effective index difference \( \Delta \text{Re}(n_{\text{eff}}) \) of the CPWG with volume fraction of ethanol for different P-ZnO are depicted in Fig. 8. The black, red, blue and green solid lines indicate the TM-\( \Delta \text{Re}(n_{\text{eff}}) \) variation whereas the dashed lines show the same for TE-\( \Delta \text{Re}(n_{\text{eff}}) \), respectively. Although we optimized our structure for \( P = 40\% \), but for a comparative study we also considered three other different ZnO porosity, \( P = 30\%, 50\% \) and 60\%. As the volume fraction of ethanol into P-ZnO layer increases both the TM-\( \Delta \text{Re}(n_{\text{eff}}) \) and TE-\( \Delta \text{Re}(n_{\text{eff}}) \) increase. 5\% to 100\% absorbance of ethanol vapor makes a 0.31\% to 6.62\% TM-\( \Delta \text{Re}(n_{\text{eff}}) \) change for \( P = 40\% \) whereas a much lower value only 0.02\% to 0.38\% TE-\( \Delta \text{Re}(n_{\text{eff}}) \) change is observed for same porosity, shown by red solid and dashed lines in Fig. 8(a) main and inset, respectively. For other ZnO porosity, such as \( P = 30\% \), the TM-\( \Delta \text{Re}(n_{\text{eff}}) \) shows a change from 0.24\% to 5.13\% for 5\% to 100\% ethanol vapor absorption. On the other hand, P-ZnO with porosity \( P = 60\% \), a higher TM-\( \Delta \text{Re}(n_{\text{eff}}) \) change from 0.41\% to 9.24\% can be observed for the same volume fraction of ethanol. Thus, higher porosity shows better quasi-TM effective index change. We have also studied the CPWG's quasi-TM modal sensitivity with the volume fraction of absorbed ethanol. The black star, red ball, blue triangle and cyan diamond markers in Figs. 9(a) and (b) show the real effective index refractometric sensitivity \( \frac{\partial \text{Re}(n_{\text{eff}})}{\partial \Delta \text{Re}(n_{\text{eff}})} \) and normalized waveguide attenuation sensitivity \( \frac{\Delta \text{Re}(n_{\text{eff}})}{\Delta \text{Im}(n_{\text{eff}})} \) variations for different porosity, \( P = 30\%, 40\%, 50\% \) and 60\%, respectively. For each P-ZnO layer, the \( \text{S}_{\text{Re(TM)}} \) and \( \text{S}_{\text{Im(TM)}} \) initially decrease up to \( \approx 15\% \) ethanol absorption and then increases as the volume fraction of ethanol increase. Figs. 9(a) and (b) also indicate that a P-ZnO layer with lower porosity (\( P = 30\% \)) shows higher \( \text{S}_{\text{Re(TM)}} \) and \( \text{S}_{\text{Im(TM)}} \) (black stars) than a P-ZnO layer with double porosity (\( P = 60\% \)), shown by cyan diamonds. In the case of waveguide based sensor design, the \( \text{S}_{\text{Re(TM)}} \) is more important than \( \text{S}_{\text{Im(TM)}} \). The result in Fig. 9(a) shows a much higher \( \text{S}_{\text{Re(TM)}} \) (\( \approx 0.71 \) per RIU) can be achieved with our proposed CPWG structure. Besides, Fig. 9(b) reveals that the normalized attenuation of the CPWG is less sensitive to slot refractometric changes. This indicates a very small loss change due to different volume fraction of ethanol into P-ZnO.

Fig. 8 demonstrates that a P-ZnO layer with high porosity is good for detection of refractometric changes due to ethanol absorption whereas, in terms of waveguide sensitivity (Fig. 9(a) and (b)), a P-ZnO layer with lower porosity shows higher effectiveness. This contradictory result can be explained with the help of Fig. 1. Equivalent refractive index variation of 60\% P-ZnO layer with volume fraction of ethanol is much steeper than 30\% P-ZnO layer. This makes the CPWG \( \text{S}_{\text{Re(TM)}} \) and \( \text{S}_{\text{Im(TM)}} \) higher for a P-ZnO layer having lower porosity.

V. CPWG INCORPORATED MACH-ZEHNDER INTERFEROMETER (MZI)

To determine the effective index change during ethanol vapor sensing process, a Mach-Zehnder interferometer (MZI) could be used as a transducer device. The MZI schematic is shown in Fig. 2(d) where two parallel arms are connected with

Fig. 10. MZI normalized output power (\( P_{\text{norm}} \)) and phase sensitivity |\( \partial P_{\text{norm}} / \partial \Delta \phi \)| variations against volume fraction of ethanol into P-ZnO. Blue diamond, red star, black square and green triangle markers with dashed lines denote sinusoidal |\( \partial P_{\text{norm}} / \partial \Delta \phi \)| variations for different porosity, \( P = 30\%, 40\%, 50\% \) and 60\%, respectively. The solid blue, red, black and green lines indicate cosine natured \( P_{\text{norm}} \) variations for all four P-ZnO layers.
one input and one output by using well designed 3 dB optical
splitters. Our proposed CPWG is incorporated in MZI arms.
One arm is called sensing arm where the integrated CPWG is
passed through ethanol vapor filled gas chamber to measure
the volume fraction of ethanol and while another CPWG is
used in reference arm. The insertion phase difference ($\Delta \phi$)
between sensing and reference arm could be measured from
the effective index change $\Delta R e(n_{eff})$ due different volume
fraction of ethanol, as

$$\Delta \phi = \frac{2\pi}{\lambda} \cdot \Delta R e(n_{eff}) \cdot L \quad (6)$$

Here, $L$ denotes the CPWG incorporated MZI arm length. A
$\pi$ phase difference between sensing and reference arm makes
a destructive interference that results a zero MZI output. The
CPWG incorporated MZI arm length are calculated as 7.51,
6.02, 5.15 and 4.59 $\mu$m for each type of P-ZnO layer having
porosity, $P = 30\%$, 40\%, 50\% and 60\%, respectively. Thus,
higher porosity gives higher $\Delta n_{eff}$ which results shorter $L$.
Same optimized design parameters ($W_{core} = 450 \text{ nm, } t_{slot} =
100 \text{ nm, } t_{Si} = 220 \text{ nm and } t_{ag} = 100 \text{ nm}$) are used for CPWG
structure. We have also studied the corresponding propagation
loss arises due to different CPWG length and a much low loss
value around 0.2 dB has been calculated for each of the
CPWG with their aforementioned lengths. More precisely,
with and without ethanol vapor the waveguide loss change in
CPWG incorporated MZI arms are 0.045 dB for $P = 30\%$,
40\% and 50\% and 0.047 dB for $P = 60\%$, respectively.
Although, CPWG has high loss compared to conventional
dielectric waveguide however, the small footprint of CPWG
provides much lower propagation loss.

The normalized output power ($P_{norm}$) of CPWG
incorporated MZI carries the $\Delta R e(n_{eff})$ information in terms
of $\Delta \phi$, is given by

$$P_{norm} = \frac{P_{out}}{P_{in}} = \frac{1}{2} e^{-2\alpha l} (1 + \cos \Delta \phi) \quad (7)$$

Here, $\alpha$ is the attenuation constant of the waveguide. All the
MZI powers are normalized with respect to the input power
$P_{in}$. The normalized output power ($P_{norm}$) have a cosine
variation with phase difference. Often it is assumed that the
attenuation ($\alpha$) is same for both MZI arms with identical
waveguides. however, for sensing purpose, the reference and the
sensing arm waveguides may have different attenuations,
$\alpha_{ref} = \alpha$ and $\alpha_{sen} = \alpha \pm \Delta \alpha_{sen}$, respectively. The sensing
waveguide attenuation is modified by a small change $\Delta \alpha_{sen}$
due to different absorption levels of ethanol vapor. It can be
shown that, this modifies the normalized MZI output power as

$$P_{norm} = \frac{1}{2} e^{-2\alpha L} e^{-\Delta \alpha_{sen} L} \cosh(\Delta \alpha_{sen} L) (1 + F \cos \Delta \phi) \quad (8)$$

Here, the $F$ is identified as interferometric fringe contrast,
which depends on $\Delta \alpha_{sen}$ as, $F = 1/cosh(\Delta \alpha_{sen} L)$.
Additionally, a section of the equation (8) could be termed as

power fraction ($PF = e^{-\Delta \alpha_{sen} L} \cosh(\Delta \alpha_{sen} L)$) which indicates
the increase or decrease in power compared to the reference
arm waveguide. $P_{norm}$ is only measurable parameter that
changes with the phase difference in between sensing and
reference arms. Thus, a phase sensitivity of the device is an
important parameter which can be defined by

$$\frac{\partial P_{norm}}{\partial (\Delta \phi)} = \frac{1}{2} e^{-(2\alpha + \Delta \alpha_{sen}) L} \cosh(\Delta \alpha_{sen} L) F \sin(\Delta \phi) \quad (9)$$

The equation shows that the maximum phase sensitivity
occurs for $\Delta \phi = \frac{n}{2}$. Figure 10 shows the normalized power
($P_{norm}$) and absolute value of phase sensitivity $|\partial P_{norm}/\partial (\Delta \phi)|$ variations of proposed CPWG incorporated
MZI against ethanol volume fraction for different P-ZnO.
Different markers with dashed lines and solid lines are used to
indicate the $|\partial P_{norm}/\partial (\Delta \phi)|$ and $P_{norm}$ variations. Blue, red,
black and green solid lines indicate cosine variations of $P_{norm}$
with volume fraction of ethanol into P-ZnO of porosity, $P =
30\%, 40\%, 50\%$ and 60\%, respectively. This figure depicts
that 100% ethanol vapor absorption in sensing arm makes a $\pi$
phase difference with zero MZI output and a 5% (considered
as minimum) volume fraction of ethanol imposes a minimum
phase difference with maximum 60\%, 70\%, 76\% and 81\% light output for 30\%, 40\%, 50\% and 60\% P-ZnO, respectively.
Higher porosity provides better light output. The $\Delta \phi$ shows an
almost linear relationship with ethanol volume fraction. Blue
diamond, red star, black square and green triangles with
dashed lines depicts a sinusoidal variation of $|\partial P_{norm}/\partial (\Delta \phi)|$
for four different P-ZnO layers. Lower porosity ($P = 30\%$)
shows lower phase sensitivity, shown by the blue dashed line
with diamond marker, whereas, the green dashed line with
triangular marker shows a much better phase sensitivity for
porosity, $P = 60\%$. Considering device sensitivity, all ZnO
layers with different porosity, $P = 30\%, 40\%, 50\%$ and 60\%
exhibit maximum phase sensitivities of 0.30, 0.34, 0.38 and 0.40
when 51.57\%, 52.05\%, 52.59\% and 53.16\% of the ZnO
poros are filled by the condensed ethanol, respectively when
an exact $\pi$ phase difference is obtained in between sensing and
reference arms. A MZI with lossless identical waveguide exhibits
almost same phase sensitivities for all P-ZnO layers.
In this CPWG incorporated MZI, the balance between both
arms break down due to different attenuations ($\alpha_{ref} \neq \alpha_{sen}$).
To make an error-free MZI design, the device attenuation
should be controlled in a way such that it does not reduce the
interferometer balance. In our study, for all volume fractions
of ethanol into 30\%, 40\%, 50\% and 60\% P-ZnO the fringe
contrast ($F$) was $-0.99$ and the power fraction ($PF$) was $-0.96$.
This ($F \approx PF \approx 1$) indicates that in this case the extra
attenuation change in the sensing waveguide is very small to
cause any noticeable effect in the CPWG incorporated MZI
performance.

VI. FABRICATION CHALLENGES

The Si nano-wire could be easily realized by modern
CMOS fabrication technologies. Lithography masking and
then controlled dry-etching of a commercially available silicon-on-insulator (SOI) wafer can be used to fabricate a finite width ($W_{core}$) fixed height ($t_{Si} = 220$ nm) Si nano-wire. Although different chemical strategies are available to grow P-ZnO, such as, sol-gel, thermal decomposition, laser ablation that uses a high temperature, a low temperature synthesis mechanism using precipitation method [9, 37] could be useful to grow a controlled thickness ($t_{slot}$) P-ZnO nano layer on Si. A ZnO nanocrystal layer can be formed by using additive materials with the pure Zn based solution and then deposit it onto Si nano-wire by the process of uniform precipitation method. To achieved mesoporous crystallized ZnO, the additive materials residue need to be evaporate by heat treatment. The pore dimensions and quality could be controlled by the additive material concentration, molecular size and operating temperature. Here we considered a mesoporous ZnO layer with pore sizes between 2 to 50 nm.

VII. CONCLUSIONS

In summary, a SOI based composite plasmonic waveguide (CPWG) is investigated where a porous ZnO layer is used as a horizontal slot for ethanol vapor sensing. A H-field based FEM is used for analyses. These simulations revel that the CPWG can guide a hybrid plasmonic supernode, comprises of SPPs and dielectric mode, over a sufficiently long distance. A nano-scale (450 nm × 100 nm) field confinement is obtained and then exploited to detect the refractometric changes due to ethanol vapor absorption and condensation. All the design parameters are optimized for the best possible result. The proposed CPWG shows a high waveguide sensitivity 0.7 per RIU for 40% porous ZnO layer as horizontal slot. This CPWG is used in both arms of a compact Mach-Zehnder interferometer (MZI) to measure the refractive index change. The MZI output power with different volume fraction of absorbed ethanol into P-ZnO for various porosity also have been analyzed and reported. Different phase sensitivities (0.30, 0.34, 0.38 and 0.40) for the proposed sensors are observed for 51.57%, 52.05%, 52.59% and 53.16% ethanol condensation into horizontally slotted ZnO layer with porosity, $P$ = 30%, 40%, 50% and 60%, respectively.

Thus, numerically simulated investigation successfully serves a demonstration of label free ethanol vapor sensor using a coupled SPP and dielectric field confined in a low index nano-scale horizontal slot. In practice, due to simplicity this compact CPWG can be easily achieved with modern fabrication technologies and advanced surface chemistry. Based on the reported results, the present work shows a potential application of this composite plasmonic waveguide in environmental gas and vapor sensing mechanism.

REFERENCES


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Prof. Rahman is a Fellow of the IEEE, the Optical Society of America, and the SPIE.